#### **Application Data Sheet**

## **Application Information**

Application number::

Filing Date::	
Application Type::	Regular

Subject Matter:: Utility

Title :: BEAM HOMOGENIZER AND

LASER IRRADIATION

APPARATUS AND METHOD

OF MANUFACTURING

SEMICONDUCTOR DEVICE

Attorney Docket Number:: 0756-7197

Total Drawing Sheets:: 10
Small Entity?:: No

#### Applicant Information

Applicant Authority Type:: Inventor
Primary Citizenship Country:: Japan

Given Name:: Koichiro

Middle Name::

Family Name:: TANAKA

Name Suffix::

City of Residence:: Atsugi

State or Province of Residence:: Kanagawa

Country of Residence:: Japan

Street	of	mailing	address::
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c/o Semiconductor Energy

Laboratory Co., Ltd., 398,

Hase

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State or Province of mailing address::

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Country of mailing address::

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243-0036

## Correspondence Information

Correspondence Customer Number ::

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## Representative Information

Representative Customer Number::

31780

## **Domestic Priority Information**

Application ::	Continuity Type::	Parent Application::	Parent Filing Date::

# Foreign Priority Information

Country::	Application number::	Filing Date::	Priority Claimed::
Japan	2002-272812	09/19/2002	Yes

## **Assignee Information**

Assignee name:: Semiconductor Energy

Laboratory Co., Ltd.

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City of mailing address:: Atsugi-shi

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Country of mailing address:: Japan

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